# Terahertz Crystals

## GaSe / ZnTe – SEMICONDUCTOR TERAHERTZ CRYSTALS

#### ZnTe

ZnTe (Zinc Telluride) crystals with <110> orientation are used for THz generation by optical rectification process. Optical rectification is a difference frequency generation in media with large second order susceptibility. For femtosecond laser pulses which have large bandwidth the frequency components interact with each other and their difference produce bandwidth from 0 to several THz.

Detection of the THz pulse occurs via freespace electro-optic detection in another <110> oriented ZnTe crystal. The THz



pulse and the visible pulse are propagated collinearly through the ZnTe crystal. The THz pulse induces a birefringence in ZnTe crystal which is read out by a linearly polarized visible pulse. When both the visible pulse and the THz pulse are in the crystal at the same time, the visible polarization will be rotated by the THz pulse. Using a  $\lambda/4$  waveplate and a beamsplitting polarizer together with a set of balanced photodiodes, it is possible to map THz pulse amplitude by monitoring the visible pulse polarization rotation after the ZnTe crystal at a variety of delay times with respect

ZnTe, <110> Cut

to the THz pulse. The ability to read out the full
electric field, both amplitude and delay, is one
of the attractive features of time-domain THz
spectroscopy.

ZnTe are also used for IR optical components substrates and vacuum deposition.

NOTE: ZnTe crystal contains micro bubbles and they are visible in projection of illuminated crystal. However this does not affect the THz generation. We do not accept complains on presence of bubbles in crystal.

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Size, mm	Thickness, mm	Holder, mm	Catalogue number	Price, EUR	
10×10	0.1	Ø25.4	ZnTe-100H	2145	
10×10	0.2	Ø25.4	ZnTe-200H	1880	
10×10	0.5	Ø25.4	ZnTe-500H	1420	
10×10	1.0	Ø25.4	ZnTe-1000H	1570	
10×10	2.0	Ø25.4	ZnTe-2000H	1790	
10×10	3.0	Ø25.4	ZnTe-3000H	2510	

### GaSe

GaSe (Gallium Selenide) crystals used for THz generation shows a large bandwidth of up to 41 THz. GaSe is a negative uniaxial layered semiconductor with a hexagonal structure of 62 m point group and a direct bandgap of 2.2 eV at 300 K. GaSe crystal features high damage threshold, large nonlinear optical coefficient (54 pm/V), suitable transparent



GaSe crystal mounted in Ø25.4 mm holder

range, and low absorption coefficient, which make it an alternative solution for broadband mid infrared electromagnetic waves generation. Due to broadband THz generation and detection using a sub-20 fs laser source, GaSe emitter-detector system performance is considered to achieve comparable or even better results than using thin ZnTe crystals. In order to achieve frequency selective THz wave generation and detection system, GaSe crystals of appropriate thickness should be used.

NOTE: because of material structure it is possible to cleave GaSe crystal along (001) plane only. Another disadvantage is softness and fragility of GaSe.

## GaSe, Z-Cut

Clear aperture, mm	Thickness, µm	Holder, mm	Catalogue number	Price, EUR
Ø7	10	Ø25.4	GaSe-10H1	1950
Ø7	30	Ø25.4	GaSe-30H1	1625
Ø7	100	Ø25.4	GaSe-100H1	1475
Ø7	500	Ø25.4	GaSe-500H1	1460
Ø7	1000	Ø25.4	GaSe-1000H1	1635
Ø7	2000	Ø25.4	GaSe-2000H1	1810

Please note that from now all standard GaSe crystals are provided mounted into Ø25.4 mm ring holders. Crystals could be mounted into Ø40 mm holders under your request.